

SEMICONDUCTOR APPARATUS

TECHNICAL FIELD

5 The present invention relates generally to a semiconductor apparatus having a plurality of operational conditions and more particularly to the testing of the semiconductor apparatus under various operating conditions.

BACKGROUND OF THE INVENTION

10 A semiconductor memory device, such as a dynamic random access memory (DRAM) is typically tested at the end of the wafer processing steps. Various tests are performed. Such tests include a redundancy test for identifying defective cells and a reference potential test for checking the internally generated reference potentials. After the tests are performed, on-chip fuses may be programmed to use redundant circuits for replacing
15 defective memory cells or for adjusting internally generated reference potentials. The on-chip fuses may be programmed by using a laser to blow selected fuses, thus selectively creating open fuses and intact (unblown) fuses.

 After the fuses have been programmed, wafer testing is repeated to check whether the repaired chips properly function under different operating conditions. Functional devices are
20 then assembled, re-tested and shipped to customers.

 Depending on the system that the semiconductor device is to be used in, the signal input interface specifications (signals from an external bus onto an input pin of the semiconductor device) can differ. Two typical interface specifications are low voltage transistor-transistor logic (LVTTTL) and stub series terminated logic (SSTL).

In LVTTL mode, the input signal specifications are that a high logic level (V_{IH}) is 2.0 volts and a low logic level (V_{IL}) is 0.8 volts. Thus, a signal that is 2.0 volts or higher is to be detected as logic high and a signal that is 0.8 volts or lower is detected as logic low. The bus frequency in LVTTL mode can be 100 MHz and the pulse width of the reference clock signal is 10 ns.

SSTL specifications require a higher degree of precision than LVTTL specifications. Thus, the reference voltage used to evaluate whether an input signal is high or low is applied externally to the chip. V_{IH} is then defined as a potential that is 0.3 volts above the reference voltage. V_{IL} is defined as a potential that is 0.3 volts below the reference voltage. Thus, a signal that is 0.3 volts or more above the reference potential is to be detected as logic high and a signal that is 0.3 volts or more lower than the reference potential is detected as logic low. The bus frequency in SSTL mode can be 133 MHz and the pulse width of the reference clock signal is 7.5 ns.

To facilitate manufacturing in a DRAM, a wire bonding option can be used to designate a device to be either a LVTTL interface device or a SSTL interface device. Thus, both a LVTTL interface device or a SSTL interface device can be manufactured with the same mask set, but can be selectively designated during the bonding process at the end of manufacturing. In this way, dedicated bond pads can be wired to different potentials to designate between LVTTL and SSTL interface.

Referring now to FIG. 12, a circuit schematic diagram of a conventional bond option circuit is set forth and given the general reference character **1200**.

Conventional bond option circuit **1200** includes a reference potential generation circuit **101**, transfer gates (**G101** and **G102**), inverter **IV101**, resistors (**R101** and **R102**), n-

type insulated gate field effect transistor (IGFET) **N103**, and bond pads (**PAD11** and **PAD12**). Bond pad **PAD11** is connected to an input of inverter **IV101** and an input of transfer gate **G102**. Transfer gate **G102** has control inputs connected to bond pad **PAD11** and the output of inverter **IV101**. Transfer gate **G102** has an n-type IGFET **N102** and a p-type IGFET **P102**. Reference potential generation circuit **101** has an output connected to an input of transfer gate **G101**. Transfer gate **G101** has control inputs connected to bond pad **PAD11** and the output of inverter **IV101**. Transfer gate **G101** has an n-type IGFET **N101** and a p-type IGFET **P101**. Outputs of transfer gates (**G101** and **G102**) are commonly connected to provide primary reference potential **VREF0**. Resistor **R101** has one terminal connected to primary reference potential **VREF0** and another terminal connected to a drain of n-type IGFET **N103**. Resistor **R102** has one terminal connected to the drain of n-type IGFET **N103** and another terminal connected to **VSS**. N-type IGFET has a source connected to secondary reference potential **VREF** and a gate connected to receive a control signal **C1**.

The operation of conventional bond option circuit **1200** will now be described.

When bond pad **PAD11** has a logic low (**VSS**) potential applied, transfer gate **G101** is turned on and transfer gate **G102** is turned off. In this way, primary reference potential **VREF0** becomes the potential generated by reference potential generation circuit **101**. If bond pad **PAD11** has a logic high potential, transfer gate **G101** is turned off and transfer gate **G102** is turned on. In this way, primary reference potential **VREF0** becomes the potential applied to bond pad **PAD11**.

When control signal **C1** is high, secondary reference potential **VREF** is a potential determined by the ratio resistors (**R101** and **R102**), which form a voltage divider circuit, and the potential of primary reference potential **VREF**. During this time, no external source

should be applied to pad PAD12. When control signal C1 is low, secondary reference potential VREF has a potential determined by the potential of an external source applied to pad PAD12.

Referring now to FIG. 13, a conventional semiconductor memory device is set forth in a block schematic diagram and given the general reference character **1300**.

Conventional semiconductor memory device includes a voltage-down circuit **102**, voltage up circuit **103**, memory cell array **104**, redundant cells **105**, sense amplifier **106**, row decoder **107**, address buffer **108**, command-clock buffer **109**, redundancy evaluation circuit **110**, fuse circuit **110a**, and data I/O buffer **111**.

Voltage-down circuit **102** receives primary reference potential VREF0 and generates an internal voltage VINTS that is used for the memory cell array **104**, redundant cells **105** and sense amplifier **106**. Primary reference potential VREF0 is 2.1 Volts. Internal voltage VINTS has a lower potential than the primary reference potential.

Voltage-up circuit **103** receives primary reference potential VREF0 and generates an internal voltage VBOOT that is used for row decoder **107**. Internal voltage VBOOT has a higher potential than the primary reference potential.

Address buffer **108**, command-clock buffer **109**, and data I/O buffer **111** receives secondary reference potential VREF. Secondary reference potential VREF is used as in input level reference in circuits that receive externally generated signals.

Address buffer **108** receives external address signals ADD and provide internal address signals to row decoder **107** and redundancy evaluation circuit **110**. Redundancy evaluation circuit **110** determines whether the received internal address signals match a defective address (based on a programmed state of fuse circuit **110a**). If so, the row decoder

107 is disabled and a row of redundant cells is selected from redundant cells 105. If not, the row decoder 107 is enabled and a row of memory cells is selected from memory cell array 104.

Command-clock buffer 109 receives a column address strobe signal CAS, write-enable signal WE, chip-select signal CS, and clock signal CLK. Command-clock buffer 109 provides control for read/write operations from/to memory cell array 104.

Sense amplifier 106 senses data from a selected row of memory cells and data I/O buffer 111 provides a read/write circuitry to provide data to or receive data from external data pins DQ.

Referring now to FIG. 14, a circuit diagram of an input buffer is set forth and designated by the general reference character 1400. Input buffer 1400 can correspond to input buffers that receive external signals in address buffer 108, command-clock decoder 109, or data I/O buffer 111.

Input buffer 1400 includes p-type IGFETs (P11 and P12) and n-type IGFETs (N11 and N12). N-type IGFETs N11 and N12) are input devices and p-type IGFETs (P11 and P12) are load devices. P-type IGFET P11 has a source connected to supply potential VDD, and a drain and gate connected to a drain of n-type IGFET N11. P-type IGFET P12 has a source connected to supply potential VDD, a drain connected to a drain of n-type IGFET N11, and a gate connected to the gate of p-type IGFET P11. N-type IGFET N11 has a gate connected to receive secondary reference potential VREF and a source connected to supply potential VSS. N-type IGFET N12 has a gate connected to receive an input signal IN and a source connected to supply potential VSS.

Input buffer 1400 operates as a comparator. If the potential of input signal IN is less

than secondary reference potential VREF, n-type transistor **N11** is turned on harder than n-type transistor **N12** and output signal OUT is high. If the potential of input signal IN is higher than secondary reference potential VREF, n-type transistor **N12** is turned on harder than n-type transistor **N11** and output signal OUT is low. In this way input buffer **1400** acts
5 as an inverting input buffer in that output signal OUT is inverted with respect to input signal IN. Input buffer **1400** is a differential amplifier and can detect small differences in potential between input signal IN and secondary reference potential VREF.

Referring to FIGS. 12, 13, and 14, in a conventional semiconductor device **1300** incorporating conventional bond option circuit **1200** and input buffer **1400**, the device is
10 tested at the end of the manufacturing process and before packaging. Such a wafer testing procedure is carried out by applying a potential of 2.1 volts to bond pad **PAD11** of bond option circuit. With a potential of 2.1 volts applied to bond pad **PAD11**, pass gate **G102** is turned on and pass gate **G101** is turned off. The 2.1 volts applied to bond pad **PAD11** provides the primary reference voltage VREF0. Control signal C1 is high and the secondary
15 reference potential VREF becomes a potential that is proportional to primary reference voltage VREF0 based on the values of resistors (**R101** and **R102**).

An external potential is applied for testing because the potential provided by reference potential generation circuit **101** can vary among wafers that are processed in different batches or lots. In this way, the test results can be compared with results obtained
20 when reference potential generation circuit **101** generates primary reference voltage VREF0.

After wafer testing, the device is programmed to operate in either LVTTL mode or SSTL mode. If the device is programmed to operate in LVTTL mode, bond pad **PAD11** is bonded to supply potential VSS, control signal C1 is set at a high potential and bond pad

PAD12 is left to float. In this way, pass gate **G102** is turned off and pass gate **G101** is turned on. Reference potential generation circuit **101** provides primary reference potential **VREF0**. N-type IGFET **N103** is turned on. Secondary reference potential **VREF** is proportional to primary reference potential **VREF0** based on the values of resistors (**R101** and **R102**).

5 If the device is programmed to operate in SSTL mode, bond pad **PAD11** is bonded to supply potential **VSS**, control signal **C1** is set at a low potential (**VSS**) and bond pad **PAD12** is bonded to an external pin for receiving a reference potential. In this way, pass gate **G102** is turned off and pass gate **G101** is turned on. Reference potential generation circuit **101** provides primary reference potential **VREF0**. N-type IGFET **N103** is turned off. Secondary
10 reference potential **VREF** is equal to the externally applied reference potential receive at bond pad **PAD12**. The potential externally applied to bond pad **PAD12** is 1.5 volts.

Referring to FIG. 14, the secondary reference potential **VREF** is generated internally when in the LVTTTL mode and externally when in the SSTL mode. In both modes it is desirable to set the secondary reference potential at a mid-point between V_{IH} and V_{IL} . This
15 will give the maximum differential potential for input buffer **1400** to detect and will allow faster circuit operation and more reliable input noise margins.

As illustrated in the conventional semiconductor memory device **1300**, a separate bond pad **PAD11** is needed to allow the primary and secondary reference potentials (**VREF0** and **VREF**) to be tested. In the normal mode of operation bond pad **PAD12** is used to
20 provide secondary reference potential **VREF** for SSTL mode operation.

As a semiconductor memory devices get smaller, fewer bond pads are available that can be dedicated for bond options and testing. This is particularly true among devices having a wide DQ configuration as is typical among present day DRAMs.

In the conventional bond option circuit **1200** in FIG. 12, a separate bond pad may be required to provide the potential on the control gate of N-type IGFET **N103** in LVTTL mode and SSTL mode devices.

Also, if the primary reference potential **VREF0** supplied during the wafer test shifts, internal circuits that receive potentials based on the primary reference potential may not function correctly. Transfer gates (**G101** and **G102**) include p-type IGFETs that may have p-n junctions forward biased when a reference potential is applied to bond pad **PAD11** during testing. This can cause latch-up to occur by turning on parasitic bipolar transistors and may lead to the destruction of the device under test.

Also, when testing the secondary reference potential **VREF**, control signal **C1** must be high. However, when switching back to a normal mode of operation, control signal **C1** must become low. If the switching of control signal **C1** is provided by an input buffer, then there may be problems with affecting the secondary reference potential while switching control signal **C1** and this may affect the difference between an input logic value and secondary reference potential so that input buffers may incorrectly evaluate received signals.

In view of the above discussion, it would be desirable to provide a semiconductor memory device with a reduced number of bond pads while still providing an accurate method of testing reference potentials and circuit operation. It would also be desirable to test a semiconductor device having two different input interfaces that may be selected during the manufacturing phase of the device.

SUMMARY OF THE INVENTION

According to the present embodiments, a semiconductor device can include a

reference configuration circuit. The reference configuration circuit may provide a primary reference potential VREF0 and secondary reference potential. During a wafer test mode, primary reference potential VREF0 and secondary reference potential VREF may be provided from a potential that may be applied to a bond pad.

5 According to one aspect of the embodiments, the reference configuration circuit may include a bond pad, a reference potential generation circuit, a control circuit, a reference selection circuit, and a secondary reference potential generation circuit.

According to one another aspect of the embodiments, the second reference potential may be an input buffer reference potential.

10 According to another aspect of the embodiments, the semiconductor device may be programmably configured to operate in a first operational mode or a second operational mode.

According to another aspect of the embodiments, the reference configuration circuit may include a second reference potential generator receiving the first reference potential. In
15 a normal operation, when the semiconductor device may be configured to operate in the first operational mode, the first reference potential may be generated by the first reference potential generator. When the semiconductor device is configured to operate in the second operational mode, the second reference potential may be generated by the second reference potential generator.

20 According to another aspect of the embodiments, in the test mode of operation, the second reference potential may be generated by the second reference potential generator.

According to another aspect of the embodiments, the reference configuration circuit can include a fuse that may be intact in the test mode of operation and blown in the first

operational mode.

According to another aspect of the embodiments, a control circuit may provide a first control signal having a first logic level in a normal operation and a second logic level in a test operation. A reference selection circuit may receive the control signal and provide a first reference potential at a first node and a second reference potential at a second node. In the normal operation, the selection circuit may provide a potential received on the bond pad to the second node and in a test operation the selection circuit may provide the potential received on the bond pad to the first node.

According to another aspect of the embodiments, the control circuit may include a programmable device having a first state in the test operation and a second state in the normal operation.

According to another aspect of the embodiments, the reference selection circuit may include a first switch including a voltage translator that may receive the first control signal and may provide a switch control output to a control gate of a controllable impedance device that may be connected between the bond pad and the first node.

According to another aspect of the embodiments, the reference configuration may include a reference potential generation circuit coupled to the reference selection circuit. The reference selection circuit may include a second switch that may receive the first control signal and may provide a low impedance path between the reference potential generation circuit and the first node when the first control signal has the first logic level and a high impedance path between the reference potential generation circuit and the first node when the first control signal has the second logic level.

According to another aspect of the embodiments, the reference selection circuit may

include a switch that may be connected to receive the first control signal and may provide a low impedance path between the second reference potential generation circuit and the second node when the first control signal has the first logic level and a high impedance path between the reference potential generation circuit and the second node when the first control signal
5 has the second logic level.

According to another aspect of the embodiments, the second reference potential generation circuit may receive the first reference potential and generate a potential that may be proportional to the first reference potential.

According to another aspect of the embodiments, the control circuit may receive a
10 power-up signal that may force the first control signal to the second logic level during power-up.

According to another aspect of the embodiments, the semiconductor device may be programmably configured to operate in a first operational mode that may have first input signal specifications or a second operational mode that may have second input signal
15 specifications.

According to another aspect of the embodiments, the first reference generation circuit may include at least one programmable device for adjusting the potential provided.

According to another aspect of the embodiments, the semiconductor device may include a voltage-down circuit that may receive the first reference potential and may provide
20 an internal supply potential having a potential less than the first reference potential.

According to another aspect of the embodiments, the semiconductor device may include a voltage-up circuit that may receive the first reference potential and may provide an internal supply potential having a potential greater than the first reference potential.

According to another aspect of the embodiments, the semiconductor device may be a semiconductor memory device. The first operational mode may be a SSTL mode and the second operational mode may be a LVTTL mode.

According to another aspect of the embodiments, a method for testing a semiconductor device during a wafer test mode, a primary reference potential VREF0 and a secondary reference potential VREF may be provided from a potential that may be applied to a bond pad. A reference generation circuit may be included on the semiconductor device and may generate a reference potential. The reference generation circuit may include at least one programmable device for adjusting the reference potential.

According to another aspect of the embodiments, the method for testing the semiconductor device may include cutting a fuse after testing the semiconductor device.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a circuit schematic diagram of a reference configuration circuit according to an embodiment.

FIG. 2 is a block schematic diagram of a semiconductor memory device according to one embodiment.

FIG. 3 is a circuit schematic of switch according to an embodiment.

FIG. 4 is a circuit schematic of switch according to an embodiment.

FIG. 5 is a circuit schematic diagram of reference potential generation circuit according to an embodiment.

FIG. 6 is a circuit schematic diagram illustrating operating conditions of a reference configuration circuit during the wafer test operation in the SSTL mode according to an

embodiment.

FIG. 7 is a circuit schematic diagram illustrating operating conditions of a reference configuration circuit during normal operation in the SSTL mode according to an embodiment.

5 FIG. 8 is a circuit schematic diagram illustrating operating conditions of a reference configuration circuit during the wafer test operation in the LVTTL mode according to an embodiment.

FIG. 9 is a circuit schematic diagram illustrating operating conditions of a reference configuration circuit during the normal operation in the LVTTL mode according to an
10 embodiment.

FIG. 10 is a circuit schematic of switch according to an embodiment.

FIG. 11 is a waveform illustrating power-up signal according to an embodiment.

FIG. 12 is a circuit schematic diagram of a conventional bond option circuit.

FIG. 13 is a block schematic diagram of a conventional semiconductor memory
15 device.

FIG. 14 is a circuit diagram of an input buffer.

DETAILED DESCRIPTION OF THE EMBODIMENTS

Various embodiments of the present invention will now be described in detail with
20 reference to a number of drawings.

Referring now to FIG. 1, a circuit schematic diagram of a reference configuration circuit according to an embodiment is set forth and given the general reference character **100**.

Reference configuration circuit **100** can include, a bond pad **PAD1**, a reference

potential generation circuit **1**, a control circuit **50**, a reference selection circuit **60**, and a secondary reference potential generation circuit **70**. Reference configuration circuit **100** may receive an input signal from bond pad **PAD1** and may provide a primary reference potential **VREF0** and a secondary reference potential **VREF**.

5 Reference configuration circuit **100** may provide a primary reference potential **VREF0** and a secondary reference potential **VREF** determined by a mode of operation of a semiconductor device and a potential that may be applied to bond pad **PAD1**. A semiconductor device incorporating reference configuration circuit **100** may include a LVTTTL mode of operation and a SSTL mode of operation. The modes of operation may be
10 selected during the manufacturing process. Also, a test mode may be included that can allow a semiconductor device to be tested using the reference configuration circuit **100**.

Bond pad **PAD1** may be provided as an input to control circuit **50** and reference selection circuit **60**. Control circuit **50** can provide control signals (**C2** and **C3**) to reference selection circuit **60**. Reference selection circuit **60** can receive a reference potential from
15 secondary reference potential generation circuit **70** and a reference potential from reference potential generation circuit **1**. Reference selection circuit may provide a primary reference potential **VREF0** and a secondary reference potential **VREF**.

Control circuit **50** can include switches (**SW1**, **SW2**, **SW3**, and **SW7**), a resistor **R1**, and a fuse **F1**. Switch **SW1** can selectively apply a potential to resistor **R1** based on a mode
20 of operation (LVTTTL mode or SSTL mode). Resistor **R1** may have a terminal connected to fuse **F1** and an input of switch **SW2**. Fuse **F1** may be connected between resistor **R1** and a ground potential **VSS**. Switch **SW2** may selectively apply a potential provided by a node connection of resistor **R1** and fuse **F1** to an input of switch **SW3**. Switch **SW3** may receive

a potential from pad PAD1 and selectively provide a control signal C2 to reference selection circuit 120. Switch SW7 may apply a control signal C3 to switch SW8. Switch SW8 may receive a reference potential from secondary reference potential generation circuit 70 and may selectively provide secondary reference potential VREF based on a mode of operation.

- 5 Reference selection circuit 60 can include switches (SW4, SW5, SW6, and SW8). Switch SW4 can be connected to bond pad PAD1 and may selectively connect bond pad PAD1 to primary reference potential VREF0 or an input to switch SW6 based on the logic level of control signal C2. When control signal has a high logic level, switch SW4 may connect pad PAD1 to primary reference potential VREF0. When control signal C2 has a low
- 10 logic level, switch SW4 may connect bond pad PAD1 to an input of switch SW6. Switch SW5 can selectively connect a reference potential from reference potential generation circuit 1 to primary reference potential VREF0 based on the logic level of control signal C2. When control signal C2 has a low logic level, switch SW5 may be in a closed position. When control signal C2 has a high logic level, switch SW5 may be in an open position. Switch
- 15 SW6 may connect secondary reference VREF to switch SW4 in one mode of operation and may provide an open circuit in another mode of operation. Switch SW8 may connect a reference potential from secondary reference potential generation circuit to secondary reference potential VREF based on a logic level of control signal C3. When control signal C3 has a high logic level, switch SW8 may connect a reference potential from secondary
- 20 reference potential generation circuit to secondary reference potential VREF.

Secondary reference potential generation circuit 70 can include resistors (R2 and R3). Resistor R2 may have a terminal connected to primary reference potential VREF0 and another terminal connected to a terminal of resistor R3 and an input to switch SW8. Resistor

R3 may have another terminal connected to ground potential VSS.

Switches (SW1, SW2, SW6, and SW7) may have an SS connection and an LV connection. When the semiconductor device is to operate in the SSTL mode, switches (SW1, SW2, SW6, and SW7) may be programmed to connect to the SS connection. When the semiconductor device is to operate in the LVTL mode, switches (SW1, SW2, SW6, and SW7) may be programmed to connect to the LV connection. Switches (SW1, SW2, SW6, and SW7) may be programmable metal mask options, as just one example.

Referring now to FIG. 2, a semiconductor memory device according to one embodiment is set forth in a block schematic diagram in given the general reference character 200.

Semiconductor memory device 200 can include the reference configuration circuit 100 of FIG. 1 (not illustrated in FIG. 2). Semiconductor memory device 200 may include a voltage-down circuit 2, voltage up circuit 3, memory cell array 4, redundant cells 5, sense amplifier 6, row decoder 7, address buffer 8, command-clock buffer 9, redundancy evaluation circuit 10, fuse circuit 10a, and data I/O buffer 11.

Voltage-down circuit 2 may receive primary reference potential VREF0 (from reference configuration circuit 100 of FIG. 1) and generate an internal voltage VINTS that may be used for the memory cell array 4, redundant cells 5, and sense amplifier 6. Primary reference potential VREF0 may be 2.1 Volts, as just one example. Internal voltage VINTS may have a lower potential than the primary reference potential.

Voltage-up circuit 3 may receive primary reference potential VREF0 (from reference configuration circuit 100 of FIG. 1) and generate an internal voltage VBOOT that is used for row decoder 7. Internal voltage VBOOT can have a higher potential than the primary

reference potential. Voltage-up circuit **3** may also provide internal voltage VBOOT to reference configuration circuit **100** of FIG. 1.

Address buffer **8**, command-clock buffer **9**, and data I/O buffer **11** may receive secondary reference potential VREF. Secondary reference potential VREF may be used as in
5 input level reference in circuits that receive externally generated signals.

Address buffer **8** may receive external address signals ADD and provide internal address signals to row decoder **7** and redundancy evaluation circuit **10**. Redundancy evaluation circuit **10** may determine whether the received internal address signals match a defective address (based on a programmed state of fuse circuit **10a**). If so, the row decoder **7**
10 may be disabled and a row of redundant cells may be selected from redundant cells **5**. If not, the row decoder **7** may be enabled and a row of memory cells may be selected from memory cell array **4**.

Command-clock buffer **9** may receive a column address strobe signal CAS, write-enable signal WE, chip-select signal CS, and clock signal CLK. Command-clock buffer **9**
15 may provide control for read/write operations from/to memory cell array **4**.

Sense amplifier **6** may sense data from a selected row of memory cells and data I/O buffer **11** may provide a read/write circuitry to provide data to or receive data from external data pins DQ.

Referring now to FIG. 3, a circuit schematic of switch **SW4** according to an
20 embodiment is set forth.

Switch **SW4** may be electrically connected to bond pad **PAD1**. Switch **SW4** may electrically connect bond pad **PAD1** to primary reference potential VREF0 or an input to switch **SW6** based on a logic level of control signal C2. Switch **SW4** may include a

multiplexer **310** and a voltage translator **320**.

Multiplexer **310** may include n-type IGFETs (**N1** and **N2**). N-type IGFET **N1** may have a source connected to bond pad **PAD1**, a drain connected to primary reference potential **VREF0**, and a gate connected to node **ND1** of voltage translator. N-type IGFET **N2** may have a source connected to bond pad **PAD1**, a drain connected to an input of switch **SW6**, and a gate connected to node **ND2** of voltage translator.

Voltage translator **320** may include n-type IGFETs (**N3** and **N4**), p-type IGFETs (**P1** and **P2**), and an inverter **IV1**. N-type IGFET **N3** may have a source connected to ground potential **VSS**, a drain connected to node **ND2** and a gate connected to receive control signal **C2**. N-type IGFET **N4** may have a source connected to ground potential **VSS**, a drain connected to node **ND2** and a gate connected to receive control signal **C2** through inverter **IV1**. P-type IGFET **P1** may have a source connected to internal voltage **VBOOT**, a drain connected to node **ND2** and a gate connected to node **ND1**. P-type IGFET **P2** may have a source connected to internal voltage **VBOOT**, a drain connected to node **ND1** and a gate connected to node **ND2**. P-type IGFETs (**P1** and **P2**) may be cross-coupled.

Depending on the logic level of control signal **C2**, voltage translator **320** may provide internal voltage **VBOOT** to either node **ND1** or node **ND2**. Internal voltage **VBOOT** may be a boosted voltage that may have a higher potential than a potential applied to bond pad **PAD1** by at least a threshold voltage of a n-channel IGFET (for example IGFETs (**N1** and **N2**)). In this way, there may be no potential loss across n-channel IGFETs (**N1** and **N2**) when activated.

Referring now to FIG. 4, a circuit schematic of switch **SW3** according to an embodiment is set forth.

Switch **SW3** may include an inverter **IV2** and a NOR gate **NOR1**. Inverter **IV2** may

have an input connected to bond pad **PAD1** and an output connected to an input of NOR gate **NOR1**. NOR gate **NOR1** may generate control signal C2, which may be connected to switches (**SW4**, **SW5**, and **SW7**) of FIG. 1.

Referring now to FIG. 5, a circuit schematic diagram of reference potential generation circuit **1** according to an embodiment is set forth.

Reference potential generation circuit **1** may be used as reference potential generation circuit **1** of FIG. 1.

Reference potential generation circuit **1** may receive a reference potential VR and may generate primary reference potential VREF0.

Reference potential generation circuit **1** may include a differential amplifier **12**, a control circuit **510**, and a programmable potential translation circuit **520**.

Differential amplifier **12** may receive reference potential VR at a positive input terminal and a feedback node N500 at a negative input terminal and may generate a control signal.

Control circuit **510** may include a p-type IGFET **P11**. P-type IGFET **P11** may have a source connected to power supply VCC, a drain connected to primary reference potential VREF0, and a control gate connected to receive an output of differential amplifier **12**.

Programmable potential translation circuit **520** may include resistors (**R11** to **R16**) and fuses (**F11** to **F14**). Resistors (**R11** to **R12**) may be connected in series between primary reference potential VREF0 and a terminal of resistor **R15**. Resistor **R15** may have another terminal connected to feedback node N500. Resistor **R16** may have a terminal connected to feedback node N500 and another terminal may be connected to a terminal of resistor **R13**. Resistors (**R13** and **R14**) may be connected in series between a terminal of resistor **R16** and

ground potential VSS. Resistors (**R11** to **R14**) may each have a fuse (**F11** to **F14**) connected across, respectively. Fuses (**F11** to **F14**) may be laser programmable fuses, as just one example.

Reference potential generation circuit **1** may receive a reference potential VR and may provide a primary reference potential VREF0 having a greater potential based on the values of resistors (**R11** to **R16**) and the states of fuses (**F11** to **F14**). Differential amplifier **12** may provide an output signal to the control circuit **510** so that p-type IGFET **P11** may provide a current to programmable potential translation circuit **520** providing a feedback signal at feedback node N500 that has a potential approximately equal to reference potential VR. Fuses (**F11** to **F14**) may be selectively programmed to adjust the primary reference potential VREF0 to a desired potential value. By cutting or blowing fuses (**F11** and/or **F12**), primary reference potential VREF0 may be increased. By cutting or blowing fuses (**F13** and/or **F14**), primary reference potential VREF0 may be decreased.

Next the configuration and operation of reference configuration circuit **100** will be described for wafer testing and normal operations for a SSTL mode and LVTTL mode of operation.

Referring now to FIG. 6, a circuit schematic diagram illustrating operating conditions of reference configuration circuit **100** during the wafer test operation in the SSTL mode according to an embodiment is set forth.

In the test mode of operation for a semiconductor device that may be selectively programmed (by bond options and / or metal switch options, for example) to operate using SSTL interface specifications, it may be desired to externally apply an internal supply potential and an input reference potential. As noted earlier, in the SSTL mode, the input

reference potential may be applied externally through a bond pad (**PAD1**, for example) during normal operations. In the test mode of operation illustrated in FIG. 6, bond pad **PAD1** may be used to externally apply primary reference potential **VREF0**. However, secondary reference potential may be generated by secondary reference potential generation circuit **70**. In this way, secondary reference potential **VREF** may be proportional to the potential externally applied on bond pad **PAD1**. Thus, both primary reference potential **VREF0** and secondary reference potential **VREF** may be externally applied during a test mode.

The test mode may be used to test input characteristics and operating margins of internal circuitry on a semiconductor device, as just two examples.

Referring now to FIG. 6, in the test mode for a semiconductor device that may be selectively programmed to operate in the SSTL mode, bond pad **PAD1** may receive a potential of approximately 2.1 volts. Control circuit **50** may include fuse **F1** in an intact state. Switches (**SW1**, **SW2**, and **SW7**) may be selectively set to select the SS input. Switch **SW6** of reference selection circuit **60** may be selectively set to select the SS input.

Switch **SW1** may be programmed to apply a power supply **VCC** to a terminal of resistor **R1**. However, because fuse **F1** may be intact, ground potential **VSS** may be applied to the SS input of switch **SW2**. Thus, the L input of switch **SW3** may be selected. Because bond pad **PAD1** may receive a potential of approximately 2.1 volts, a logic high may be input to the L input of switch **SW3**. Thus, (referring to FIG. 4), inverter **IV2** may receive a logic high input and may apply a logic low to one input of NOR gate **NOR1**. The other input of NOR gate **NOR1** may receive a logic low from switch **SW2**. Thus, control signal **C2** may be logic high. Referring once again to FIG. 6, the high logic level of control signal **C2** may

then be applied (through switch **SW7**) to control signal C3. Thus control signal C3 may be logic high.

With control signal C2 at logic high, switch **SW5** may be in a high impedance state (an open circuit). Thus, reference potential generation circuit **1** may be disconnected from primary reference potential VREF0. Control signal C2 may be applied to switch **SW4**. With control signal C2 at a logic high (referring to FIG. 3), n-type IGFET **N3** may be turned on and n-type IGFET **N4** may be turned off. Node ND2 may be pulled low. Thus, p-type IGFET **P2** may be turned on and node ND1 may be pulled to internal voltage VBOOT. N-type IGFET **N2** may be turned off and n-type IGFET **N1** may be turned on. With n-type IGFET **N1** receiving internal voltage VBOOT at a control gate, the potential (approximately 2.1 volts) applied to bond pad **PAD1** may be applied to primary reference potential VREF0 with essentially no drop in potential. Thus, the potential of primary reference potential VREF0 may be essentially the same as the potential applied to bond pad **PAD1**.

Primary reference potential VREF0 may be input to secondary reference potential generation circuit **70**. Secondary reference potential generation circuit may generate a potential that is proportional to primary reference potential VREF0 as determined by a ratio of resistors (**R2** and **R3**). Because control signal C3 is logic high, the potential generated by secondary reference potential generation circuit **70** may be applied to secondary reference potential VREF.

In this way, both primary reference potential VREF0 and secondary reference potential VREF may be externally applied during a test mode. It is noted that only a single bond pad **PAD1** may be used to externally apply both primary reference potential VREF0 and secondary reference potential VREF.

Referring now to FIG. 7, a circuit schematic diagram illustrating operating conditions of reference configuration circuit **100** during normal operation in the SSTL mode according to an embodiment is set forth.

In the SSTL mode, the secondary reference potential V_{REF} may be applied externally through a bond pad (**PAD1**, for example) during normal operation. Primary reference potential V_{REF0} may be internally generated by reference potential generation circuit **1**.

Referring now to FIG. 7, in the normal mode for a semiconductor device that may be selectively programmed to operate in the SSTL mode, bond pad **PAD1** may receive a potential of approximately 1.5 volts. Control circuit **50** may include fuse **F1** in a cut or blown state. Switches (**SW1**, **SW2**, and **SW7**) may be selectively set to select the SS input. Switch **SW6** of reference selection circuit **60** may be selectively set to select the SS input.

Switch **SW1** may be programmed to apply a power supply V_{CC} to a terminal of resistor **R1**. Because fuse **F1** may be cut or blown, power supply V_{CC} may be applied to the SS input of switch **SW2**. Therefore, the H input of switch **SW3** may be selected. Thus, (referring to FIG. 4), an input of NOR gate **NOR1** may receive a logic high (V_{CC}) from switch **SW2**. Thus, control signal $C2$ may be logic low. Referring once again to FIG. 7, the low logic level of control signal $C2$ may then be applied (through switch **SW7**) to control signal $C3$. Thus control signal $C3$ may be logic low.

With control signal $C2$ at logic low, switch **SW5** may be in a low impedance state (a closed position). Thus, reference potential generation circuit **1** may be connected to generate primary reference potential V_{REF0} . Control signal $C2$ may be applied to switch **SW4**. With control signal $C2$ at a logic low (referring to FIG. 3), n-type IGFET **N3** may be turned off

and n-type IGFET **N4** may be turned on. Node **ND1** may be pulled low. Thus, p-type IGFET **P1** may be turned on and node **ND2** may be pulled to internal voltage **VBOOT**. N-type IGFET **N1** may be turned off and n-type IGFET **N2** may be turned on. With n-type IGFET **N2** receiving internal voltage **VBOOT** at a control gate, the potential (approximately 1.5 volts) applied to bond pad **PAD1** may be applied to secondary reference potential **VREF** with essentially no drop in potential. Thus, the potential of secondary reference potential **VREF** may be essentially the same as the potential applied to bond pad **PAD1**. Primary reference potential **VREF0** may be input to secondary reference potential generation circuit **70**. Secondary reference potential generation circuit **70** may generate a potential that is proportional to primary reference potential **VREF0** as determined by a ratio of resistors (**R2** and **R3**). However, because control signal **C3** is logic low, switch **SW8** may be in an open state and the secondary reference potential generation circuit **70** may be disconnected from secondary reference potential **VREF**.

In this way, secondary reference potential **VREF** may be externally applied on bond pad **PAD1** during a normal operation in **SSTL** mode. It is noted that only a single bond pad **PAD1** may be used to externally apply both primary reference potential **VREF0** and secondary reference potential **VREF** during the test mode and the same bond pad **PAD1** may be used to apply secondary reference potential **VREF** during the normal operation. Thus, chip area may be reduced.

Referring now to FIG. 8, a circuit schematic diagram illustrating operating conditions of reference configuration circuit **100** during the wafer test operation in the **LVTTL** mode according to an embodiment is set forth.

In the test mode of operation for a semiconductor device that may be selectively

programmed (by bond options and / or metal switch options, for example) to operate using LVTTL interface specifications, it may be desired to externally apply an internal supply potential and an input reference potential. As noted earlier, in the LVTTL mode, the input reference potential and internal supply potentials may be internally generated during normal operations. In the test mode of operation illustrated in FIG. 8, bond pad **PAD1** may be used to externally apply primary reference potential VREF0. However, secondary reference potential may be generated by secondary reference potential generation circuit **70**. In this way, secondary reference potential VREF may be proportional to the potential externally applied on bond pad **PAD1**. Thus, both primary reference potential VREF0 and secondary reference potential VREF may be externally applied during a test mode.

The test mode may be used to test input characteristics and operating margins of internal circuitry on a semiconductor device, as just two examples.

Referring now to FIG. 8, in the test mode for a semiconductor device that may be selectively programmed to operate in the LVTTL mode, bond pad **PAD1** may receive a potential of approximately 2.1 volts. Control circuit **50** may include fuse **F1** in an intact state. Switches (**SW1**, **SW2**, and **SW7**) may be selectively set to select the LV input. Switch **SW6** of reference selection circuit **60** may be selectively set to select the LV input.

Switch **SW1** may be programmed to an open circuit condition. Because switch **SW2** may be programmed to select the LV input, a ground potential VSS may be applied to switch **SW3**. Thus, the L input of switch **SW3** may be selected. Because bond pad **PAD1** may receive a potential of approximately 2.1 volts, logic high may be input to the L input of switch **SW3**. Thus, (referring to FIG. 4), inverter **IV2** may receive a logic high input and may apply logic low to one input of NOR gate **NOR1**. The other input of NOR gate **NOR1**

may receive a logic low from switch **SW2**. Thus, control signal **C2** may be logic high. Referring once again to FIG. 8, because switch **SW7** may be programmed to select the LV input, power supply **VCC** may be applied to control signal **C3**. Thus control signal **C3** may be logic high.

5 With control signal **C2** at logic high, switch **SW5** may be in a high impedance state (an open circuit). Thus, reference potential generation circuit **1** may be disconnected from primary reference potential **VREF0**. Control signal **C2** may be applied to switch **SW4**. With control signal **C2** at a logic high (referring to FIG. 3), n-type IGFET **N3** may be turned on and n-type IGFET **N4** may be turned off. Node **ND2** may be pulled low. Thus, p-type IGFET **P2** may be turned on and node **ND1** may be pulled to internal voltage **VBOOT**. N-type IGFET **N2** may be turned off and n-type IGFET **N1** may be turned on. With n-type IGFET **N1** receiving internal voltage **VBOOT** at a control gate, the potential (approximately 2.1 volts) applied to bond pad **PAD1** may be applied to primary reference potential **VREF0** with essentially no drop in potential. Thus, the potential of primary reference potential
10 **VREF0** may be essentially the same as the potential applied to bond pad **PAD1**.

Primary reference potential **VREF0** may be input to secondary reference potential generation circuit **70**. Secondary reference potential generation circuit may generate a potential that is proportional to primary reference potential **VREF0** as determined by a ratio of resistors (**R2** and **R3**). Because control signal **C3** is logic high, the potential generated by
20 secondary reference potential generation circuit **70** may be applied to secondary reference potential **VREF**.

In this way, both primary reference potential **VREF0** and secondary reference potential **VREF** may be externally applied during a test mode. It is noted that only a single

bond pad **PAD1** may be used to externally apply both primary reference potential VREF0 and secondary reference potential VREF.

Referring now to FIG. 9, a circuit schematic diagram illustrating operating conditions of reference configuration circuit **100** during the normal operation in the LVTTL mode according to an embodiment is set forth.

In the normal operation for a semiconductor device that may be selectively programmed to operate in the LVTTL mode, bond pad **PAD1** may be bonded to a low logic potential. Alternatively, bond pad **PAD1** may be left open and internal circuitry (not shown) may force bond pad **PAD1** to a low logic potential during power up and the low logic potential may be latched thereafter. Control circuit **50** may include fuse **F1** in an intact state. Switches (**SW1**, **SW2**, and **SW7**) may be selectively set to select the LV input. Switch **SW6** of reference selection circuit **60** may be selectively set to select the LV input.

Switch **SW1** may be programmed to an open circuit condition. Because switch **SW2** may be programmed to select the LV input, a ground potential VSS may be applied to switch **SW3**. Thus, the L input of switch **SW3** may be selected. Because bond pad **PAD1** may receive a low logic potential, logic low may be input to the L input of switch **SW3**. Thus, (referring to FIG. 4), inverter **IV2** may receive a logic low input and may apply logic high to one input of NOR gate **NOR1**. Thus, control signal C2 may be logic low. Referring once again to FIG. 9, because switch **SW7** may be programmed to select the LV input, power supply VCC may be applied to control signal C3. Thus control signal C3 may be logic high.

With control signal C2 at logic low, switch **SW5** may be in a low impedance state (a closed position). Thus, reference potential generation circuit **1** may be connected to generate primary reference potential VREF0. Control signal C2 may be applied to switch **SW4**. With

control signal C2 at a logic low (referring to FIG. 3), n-type IGFET **N4** may be turned on and n-type IGFET **N3** may be turned off. Node ND1 may be pulled low. Thus, p-type IGFET **P1** may be turned on and node ND2 may be pulled to internal voltage VBOOT. N-type IGFET **N1** may be turned off and n-type IGFET **N2** may be turned on. With n-type IGFET **N1** turned off, bond pad **PAD1** may be disconnected from primary reference potential VREF0. Switch **SW6** may be programmed to select the LV input. This may place switch **SW6** in an open circuit condition. Thus, bond pad **PAD1** may be disconnected from secondary reference potential VREF.

Primary reference potential VREF0 may be input to secondary reference potential generation circuit **70**. Secondary reference potential generation circuit may generate a potential that is proportional to primary reference potential VREF0 as determined by a ratio of resistors (**R2** and **R3**). Because control signal C3 is logic high, the potential generated by secondary reference potential generation circuit **70** may be applied to secondary reference potential VREF.

In this way, both primary reference potential VREF0 and secondary reference potential VREF may be internally generated during normal operation.

Accordingly, in the embodiment illustrated with in FIGS. 1-9, only one bond pad **PAD1** may be used for supplying a input reference voltage in the SSTL normal operation, and an internal potential and input reference potential for a test mode in both the SSTL and LVTTL modes. In normal operation in LVTTL mode, the internal potential and input reference potential may be internally generated.

In the embodiment illustrated in FIG. 1, resistors (**R1** to **R3**) may be resistive elements formed by a transistor, such as an IGFET.

When in a normal operation in SSTL mode, a high potential may be applied to switch **SW2**. This high potential may force control signal **C2** low, which may allow reference potential generation circuit **1** to generate primary reference potential **VREF0** and a potential applied to bond pad **PAD1** to be applied to secondary reference potential **VREF**. However, when a transistor is used for resistor **R1**, the response for applying a high potential to switch **SW2** may be delayed during power-up. A transistor used for resistor **R1** may not conduct until a gate potential is more than a threshold voltage. Further, a transistor used for resistor **R1** may conduct weakly when a potential from a source to drain is small. These factors can contribute to a high potential input to switch **SW2** to be delayed. This can result in an unreliable primary and secondary reference potentials (**VREF0** and **VREF**) at this time.

Referring now to FIG. 10, a circuit schematic of switch **SW3a** according to an embodiment is set forth.

Switch **SW3a** may be used as switch **SW3** in the embodiment illustrated in FIG. 1. Switch **SW3a** may include inverters (**IV2** to **IV4**), NAND gate **NAND1**, and a NOR gate **NOR1**. Inverter **IV2** may have an input connected to bond pad **PAD1** and an output connected to an input of NOR gate **NOR1**. Inverter **IV3** may have an input connected to a signal from switch **SW2** and an output connected to an input of NAND gate **NAND1**. Inverter **IV4** may have an input connected to a power-up signal **PON** and an output connected to an input of NAND gate **NAND1**. NAND gate **NAND1** may have an output connected to an input of NOR gate **NOR1**. NOR gate **NOR1** may generate control signal **C2**, which may be connected to switches (**SW4**, **SW5**, and **SW7**) of FIG. 1.

Referring now to FIG. 11, a waveform illustrating power-up signal **PON** according to an embodiment is set forth.

During power-up, a logic high power-up signal **PON** may force control signal C2 to a logic low level in the switch **SW3a** illustrated in FIG. 10. In this way, reference potential generation circuit 1 may be electrically connected through switch **SW5** to primary reference potential VREF0 and bond pad **PAD1** may be electrically connected through switches (**SW4** and **SW6**) to secondary reference potential VREF.

After power-up, power-up signal **PON** may transition to a logic low and switch **SW3a** may operate in essentially the same manner as switch **SW3** illustrated in FIG. 4.

It is understood that the embodiments described above are exemplary and the present invention should not be limited to those embodiments.

In the embodiments illustrated, a desired potential for primary reference potential VREF0 may be applied externally on bond pad **PAD1** in a test mode when the reference potential generation circuit 1 is not functioning properly. This may allow a semiconductor device to be characterized or debugged.

The test mode may be used to evaluate the proper level of reference potential generation circuit 1. Then, fuses (**F1** to **F4**, in FIG. 5) may be selectively programmed.

Switches (**SW1**, **SW2**, **SW6**, and **SW7**) may be other than metal mask optional switches. For example, switches (**SW1**, **SW2**, **SW6**, and **SW7**) may include programmable fuses, as just one example.

The above embodiments are illustrated with a semiconductor memory device such as a DRAM by way of example, but this should not be construed as a limitation. The invention may be applied to other types of semiconductor devices.

Thus, while the various particular embodiments set forth herein have been described in detail, the present invention could be subject to various changes, substitutions, and alterations

without departing from the spirit and scope of the invention. Accordingly, the present invention is intended to be limited only as defined by the appended claims.